

Vibronic progression

→ It can be seen in the absorption & emission spectra.

→ Vibronic progression means that there is a coupling to vibrational modes in a polymer or oligomer resulting in excitation from the ground state to the excited state or emission from the excited state down to the ground state.

↳ For polyatomic molecules, progressions are most often observed when the change in bond lengths upon electronic excitation coincides with the change due to a "totally symmetric" vibration. This is the same process that occurs in Resonance Raman spectra. As in HCHO, the $n-\pi^*$ transition involves excitation of an e^- from a nonbonding orbital to an antibonding π orbital which weakens & lengthens the C-O bond. This produces a long progression in the C-O stretch stretching vibration.

Vibronic spectra involve simultaneous change in the vibrational & electronic energy state of the molecule. In the gas phase vibronic transitions are accompanied by change in rotational energy also.

→ The intensity of allowed vibronic transition is governed by Franck-Condon principle.

Photoelectron spectroscopy (PES)

↳ or photoemission

↳ It refers to energy measurement of electron from solids, gases or liquid by the photoelectric effect, in order to determine the binding energies of electrons in a substance.

↳ It is an experimental technique that measures the relative energy of electrons in atoms and molecules.

↳ Scientists often use PES to study the elemental composition of materials or to characterize bonding in molecules.

⊙ Principle of PES → If a molecule is excited by a high energy photon in the U.V region of the spectrum, that has sufficient energy to ionize the molecule, the excited species will eject electrons.

Threshold frequency → For each metal there is a minimum frequency, called threshold frequency, of the incident light below which no electron are emitted how much intense the radiation may be.

↳ The no of e^- emitted from the metal surface in a given time depends on the intensity of radiation used. There are two imp. facts about the photoelectric emission →

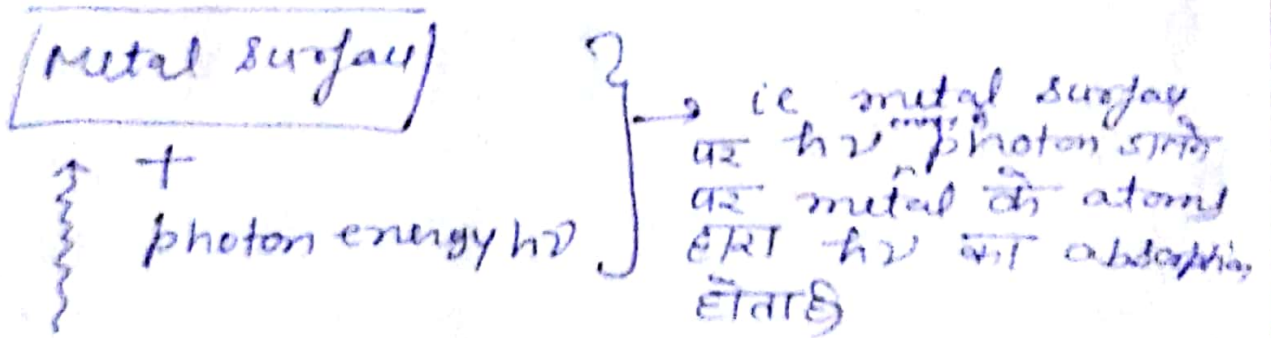
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(a) No of e^- liberated from the metal surface \propto Intensity of incident radiation.

(b) Incident radiation की frequency में increase होने पर liberated e^- की velocity बढ़ जाती है

⚡ Explanation of photoelectric emission

Acc to quantum theory, radiation consists of particles of energy, called quanta or photons of energy $h\nu$.



where $h\nu =$ photon energy

metal surface के atoms पर absorbed photon energy, $h\nu$ is equal to the sum of,

$$ie \quad h\nu = \boxed{\text{Kinetic energy of emitted electron ie } \frac{1}{2} m v^2} + \boxed{\text{energy } \phi_0 \text{ required to release the electron from the metal surface}}$$

$$h\nu = KE + \phi_0$$

The ejected e^- travel from the sample to an energy analyser where their K.E are recorded, then to a detector, which counts the no of photoelectrons at various K.E.

(4)
 ↳ Here energy (ϕ_1) is product of the work function of the metal & the electronic charge.

$$ie \quad h\nu = \frac{1}{2}mv^2 + \phi_1 \rightarrow A$$

where ν = frequency of incident radiation.

photon = KE + work function energy

↳ It is clear from this equation that $\rightarrow h\nu$ हो ϕ_1 से greater होना चाहिए $[h\nu > \phi_1]$ ie photon energy > work function

↳ So clearly the incident radiation की frequency, जहाँ तक एक definite minimum value, जिसे threshold frequency कहते हैं, को exceed नहीं करती है, तब तक electron की photoelectric emission नहीं हो सकता है.

$(\nu_0 = \text{Threshold frequency})$

We know that, $\phi_1 = h\nu_0$, so from eqn (4)

$$h\nu = \frac{1}{2}mv^2 + h\nu_0$$

$$\text{or } \frac{1}{2}mv^2 = h\nu - h\nu_0$$

$$\text{or } \boxed{\frac{1}{2}mv^2 = h(\nu - \nu_0)}$$

↳ This is Einstein's photoelectric equation

5

Einstein's equation indicates \rightarrow

(a) Incident radiation of frequency increases \Rightarrow KE liberated e^- of velocity \uparrow

(b) No electron will be emitted when frequency of incident radiation (ν) is less than threshold frequency (ν_0)

We know that $[E_1 = h\nu_0] \rightarrow$ clear that threshold frequency or threshold energy is known as work function of the metal.
Nomenclature

Metal surface + $h\nu$



Metal surface से e^- का निरगमन



Called photoelectric effect, a metal surface से निकले e^- को photoelectrons कहेंगे

or $[K.E \text{ of photoelectron} = K.E \text{ of light} - \text{Threshold Energy}]$
 $[K.E \text{ of } " = \text{light energy} - \text{Threshold Energy}]$

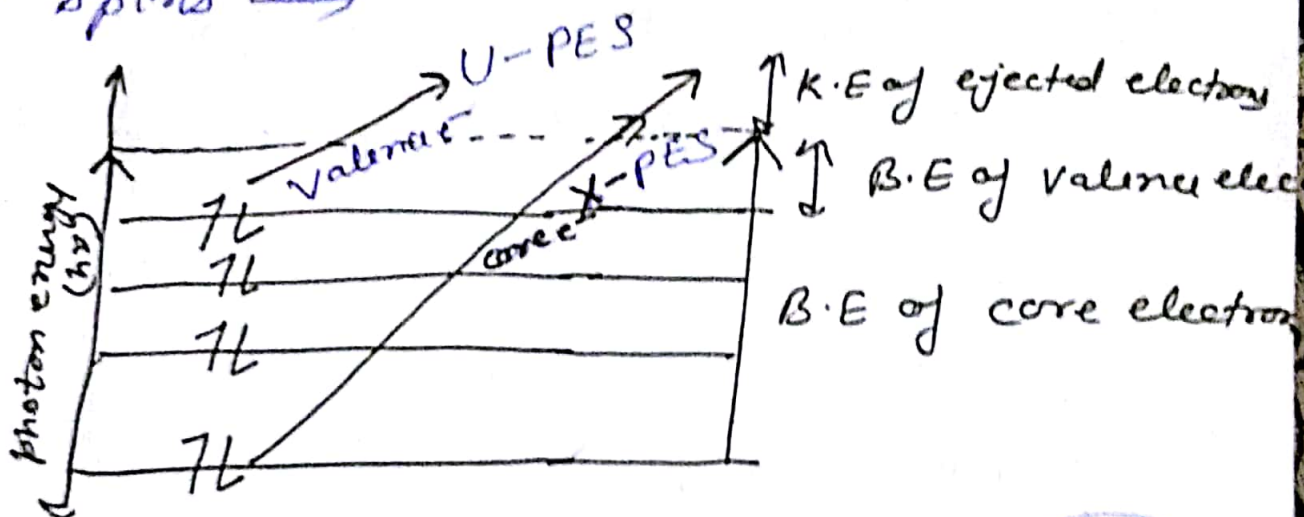
Principles

\rightarrow A technique for determining the atomic energy levels & hence the Ionization energy or binding energies of atoms or molecules

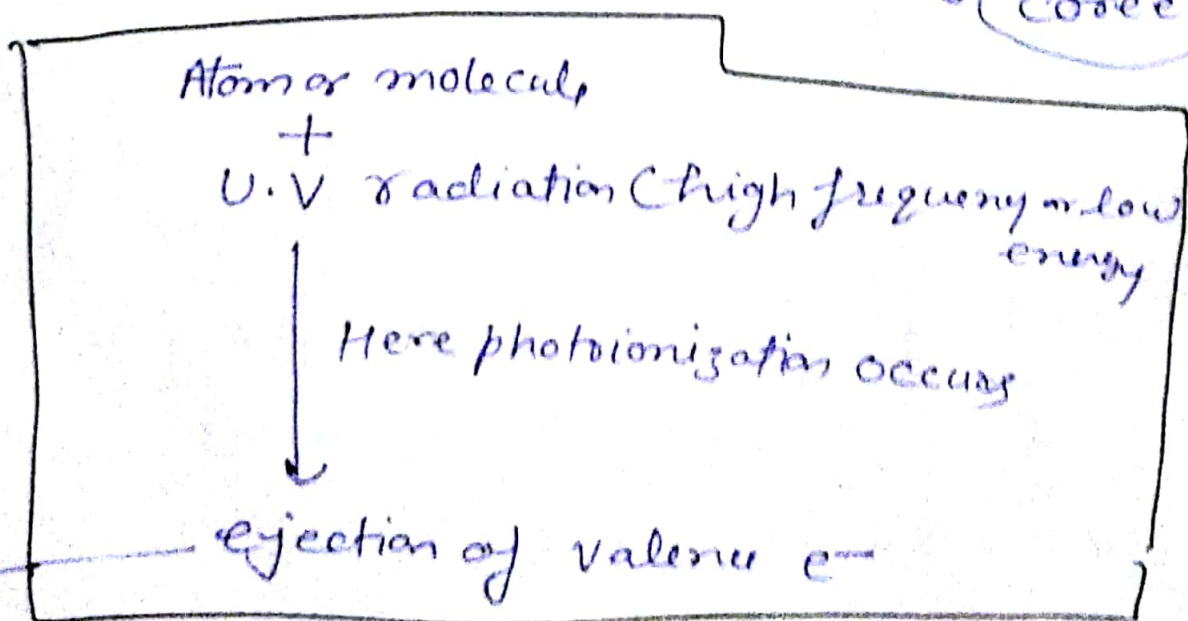
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This spectroscopy observed the ionization energies of electrons from different molecular orbitals.

↳ So consider some energy levels of an atom containing electrons with paired spins →



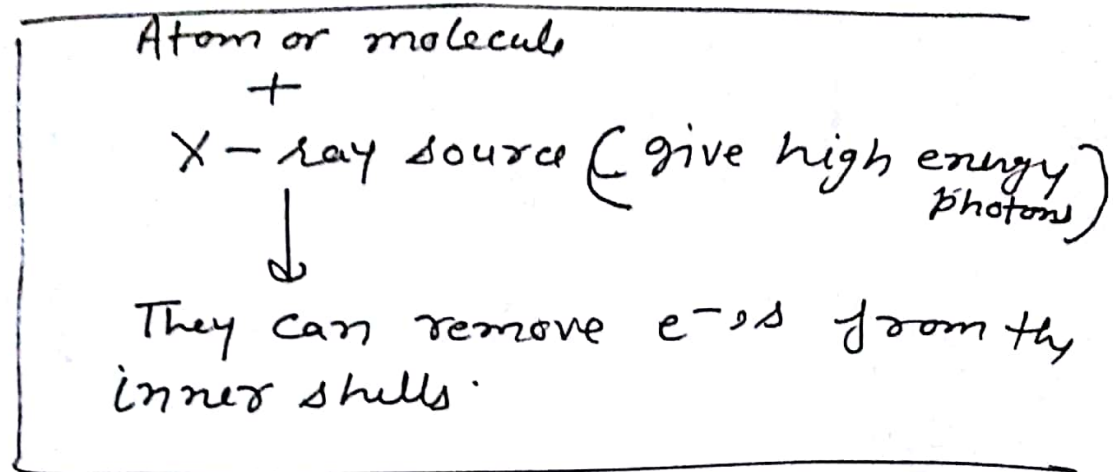
↳ The electrons are classified as Valence e⁻ and core e⁻



↳ called photo electron spectroscopy (PES) or U.V-PES
↳ K.E of these photoelectrons are measured
↳ this technique is called PES or UV-PES

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(X) X-ray sources \rightarrow It can remove core e^- from the inner shells.

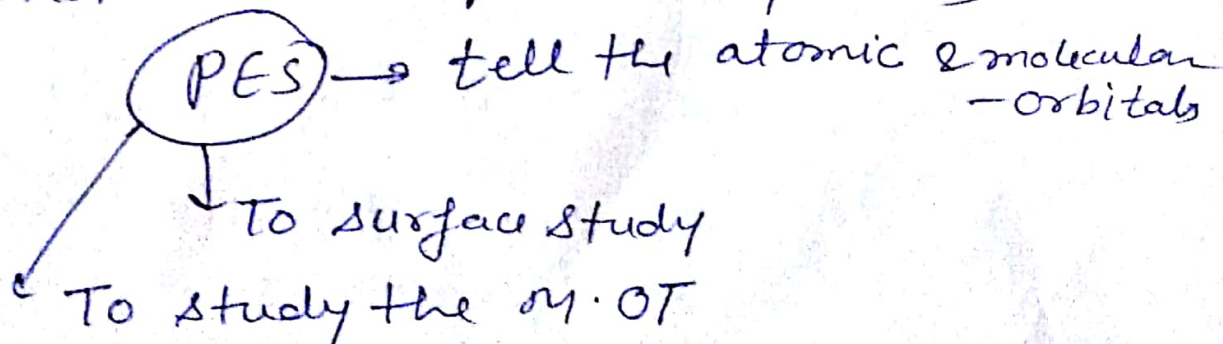


\downarrow
called X-PES or ESCA (electron - spectroscopy for chemical analysis)

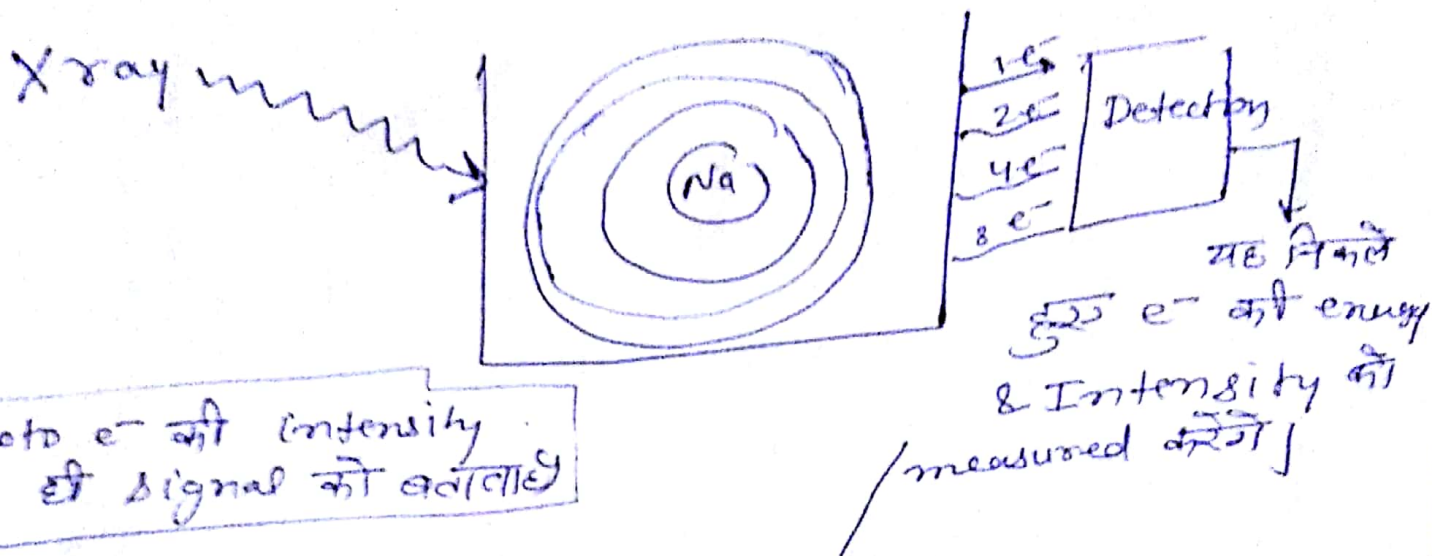
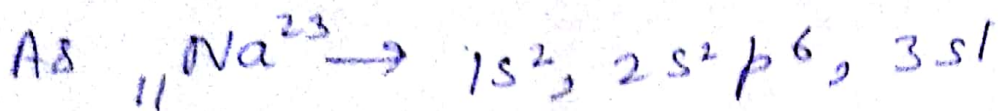
\hookrightarrow we know that, $h\nu = B.E + KE$
so $B.E = h\nu - K.E$

So work function of the metal is the energy required to remove the bulk electrons ϕ_{work} to the surface of the metal.

\rightarrow It is analogue of the ionization energy of the atom or the molecule in photoelectron spectroscopy (PES)



(B)



यह indicate करता है कि यदि 4 differed type के e^- निकल कर आयें, तो it means, it consist of 4 types of energy levels & intensity ratios

(X) X-ray PES is also known as electron spectroscopy for chemical analysis (ESCA). It can be used to identify the chemical composition of sample in surface

↓
 It depend on mostly on
 ↓
 elements & its %age
 (core e^- की Binding energy)

Auger electron spectroscopy

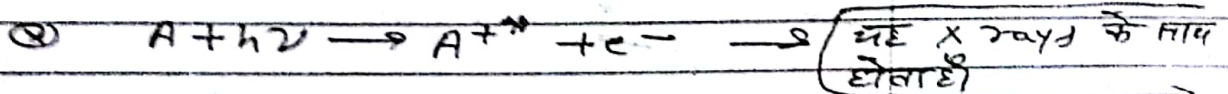
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↳ a common analytical technique used mainly in the study of surface & more generally in the area of material science
 ↳ Based on the analysis of energetic electron emitted from an excited atom after a series of internal relaxation events.

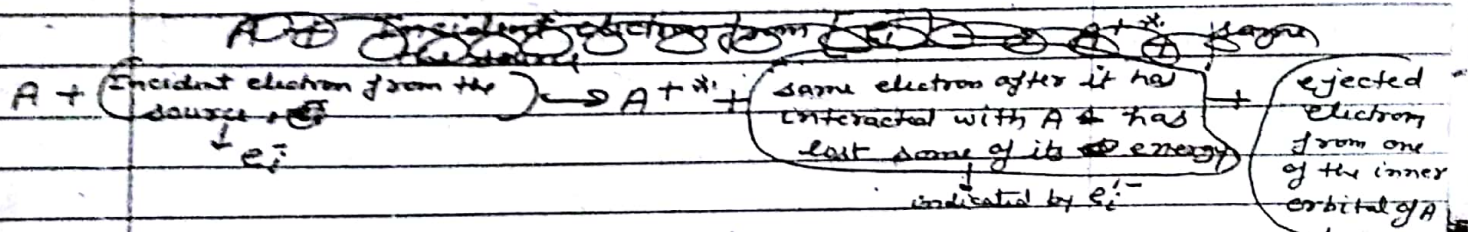
↳ It is characteristic technique for probing chemical & compositional surface environments & has found application in metallurgy etc.

↳ **AES** → two step phenomenon.

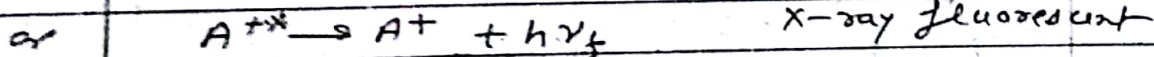
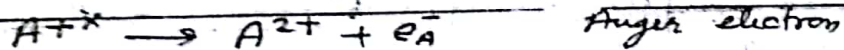
1st step formation of an electronically excited ion A^{+*} by exposing a beam of electrons / or sometimes X-ray. Ionization occurs as →



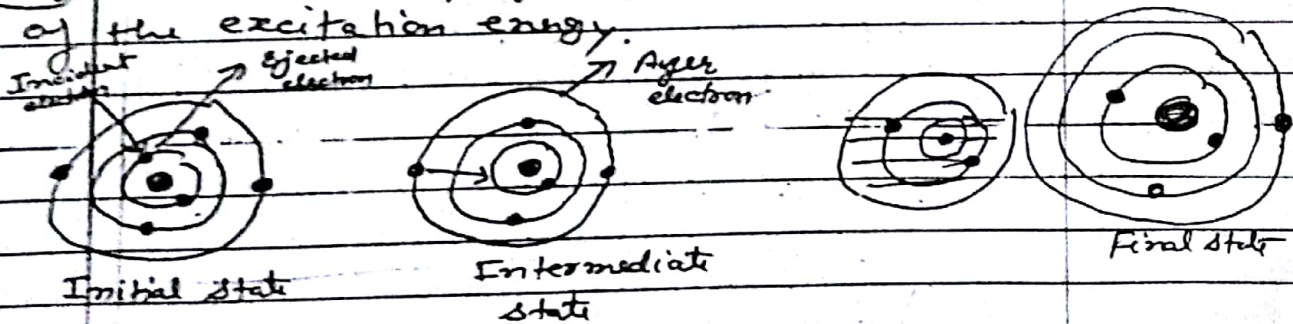
② With an electron beam, excitation is indicated as →



③ The relaxation of the excited ion A^{+*} occurs in two ways



h₂f → It is energy of fluorescence radiation is independent of the excitation energy.



↳ Auger effects occurs when the X-ray fluorescence get consumed for the ejection of outer shell electron of lower binding energy. Due to Auger effect unwanted signals appears in the photoelectron spectrum.

Koopman's theorem \rightarrow applies to the removal of an electron from any occupied molecular orbital to form a positive ion. Removal of the electron from different occupied molecular orbitals leads to the ion in different Electronic states. In this Excited state ionization energies can be measured by photoelectron spectroscopy